

**IN THE UNITED STATES PATENT AND TRADEMARK OFFICE**

In re Application of:  
Dirk Efferenn et al.

Serial No.: 10/501,464

Confirmation No.: 4558

Filed: April 8, 2005

For: METHOD FOR MASKING A  
RECESS IN A STRUCTURE  
HAVING A HIGH ASPECT  
RATIO

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Group Art Unit: 1765

Examiner: Shamim Ahmed

MAIL STOP ISSUE FEE  
Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

**CERTIFICATE OF MAILING OR TRANSMISSION**

I hereby certify that this correspondence is being deposited with the United States Postal Service with sufficient postage as first class mail in an envelope addressed to: Mail Stop Issue Fee, Commissioner for Patents, P. O. Box 1450, Alexandria, VA 22313-1450, or facsimile transmitted to the U.S. Patent and Trademark Office to fax number 571-273-8300 to the attention of Examiner Shamim Ahmed, or electronically transmitted via EFS-Web, on the date shown below:

July 24, 2007  
Date

/Joseph Jong/  
Joseph Jong

Dear Sir:

**RESPONSE TO NOTICE TO FILE CORRECTED APPLICATION PAPER DATED  
JUNE 13, 2007 (NOTICE OF ALLOWANCE MAILED)**

In response to the Notice to File Corrected Application Paper dated June 13, 2007 (copy enclosed), which followed mailing of the Notice of Allowance on April 24, 2007, Applicants request entry of the following amendments to correct drawing deficiencies identified by the Office of Patent Publication.

Amendments to the Drawings begin on page 2 of this paper and include two attached replacement sheets. Remarks/Arguments begin on page 3 of this paper.